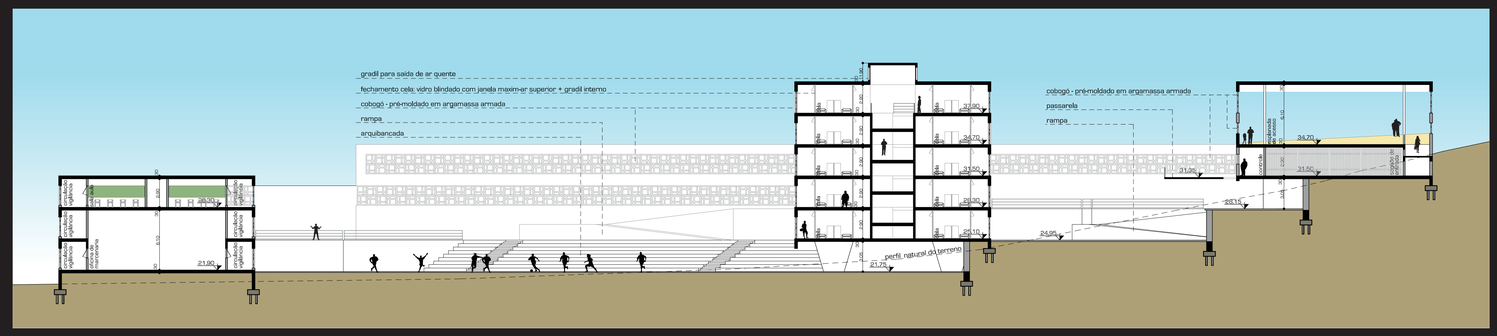
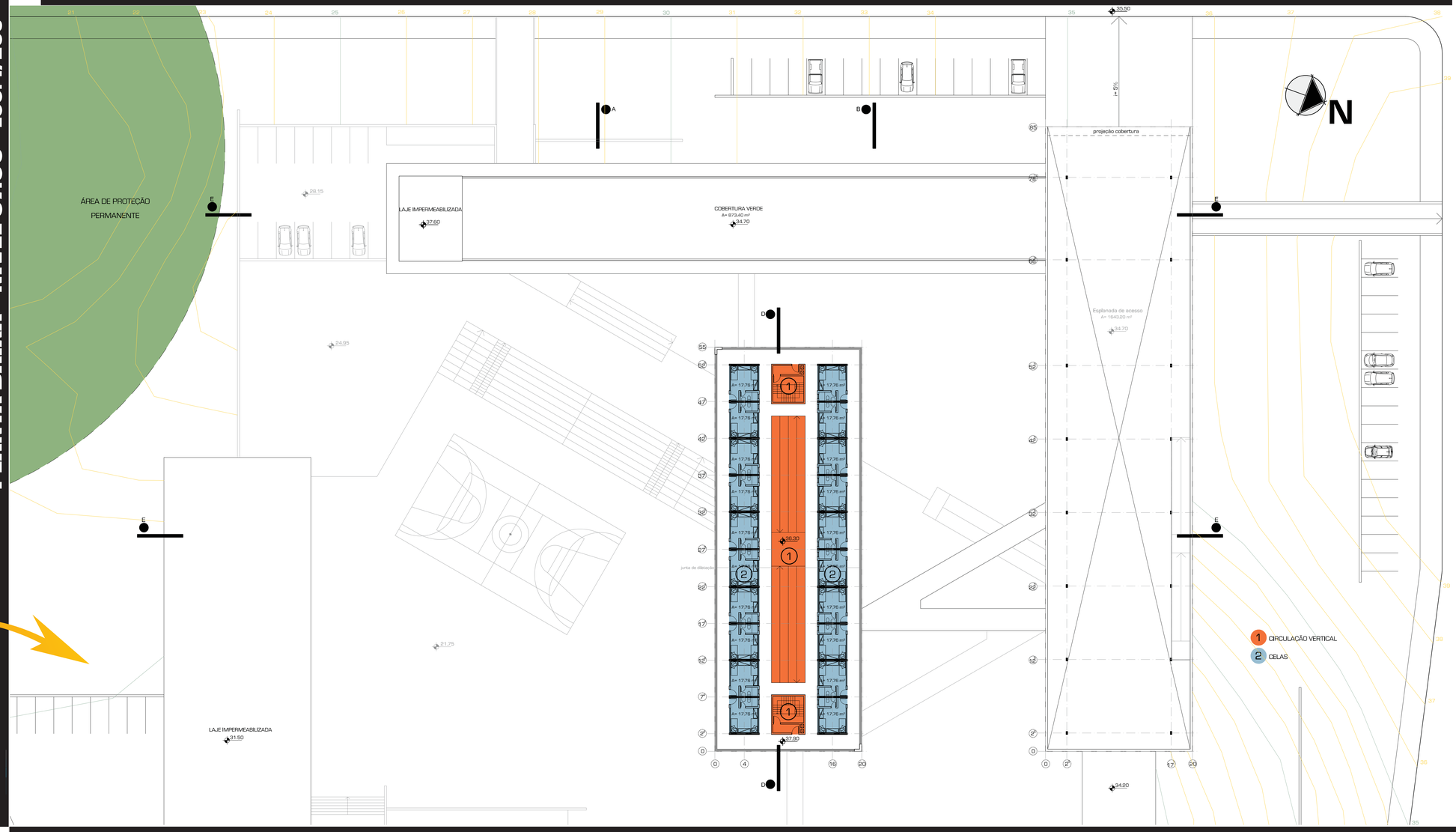
COMPLEXO PENITENCIÁRIO

pé-direito duplo na esplanada de acesso de visitantes e funcionários

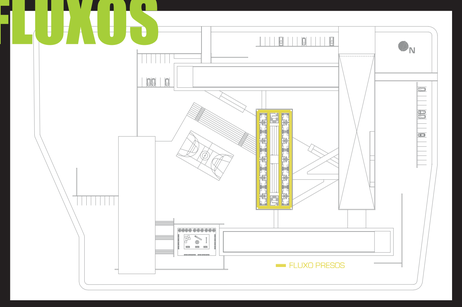
CORTE EE ESC. 1/250

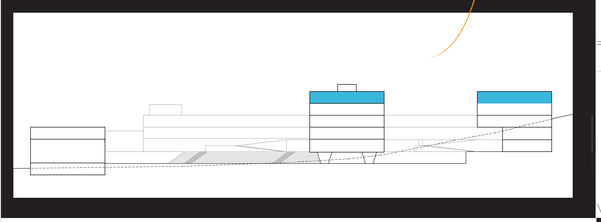


PLANTA BAIXA - NÍVEL 37.90 ESC. 1/250



FLUXOS





TFG trabalho final de graduação

Carla Hentschel

Orientador: Prof. Ms. Rinaldo Barbosa

Arquitetura e Urbanismo
Centro Universitário Feevale

2009/02